# Images of RS10 (*Picea*-whittling) residues

using Hitachi S3500N VP-SEM

The key to the images is at the beginning of the document.

The images published in this pdf are those that were used in the training portion of the experiment reported in Monnier et al. 2012, *J. Arch. Sci*. For questions, please contact Gilliane Monnier at monni003@umn.edu.
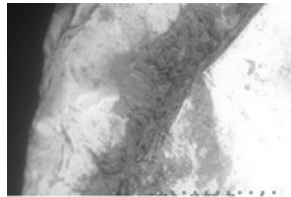
Naming conventions: 'RS' = Residue Study; 'D' = Dorsal side; 'V' = Ventral side; 'a', 'b', etc. = residue label; '25', '50', '115' = magnification used
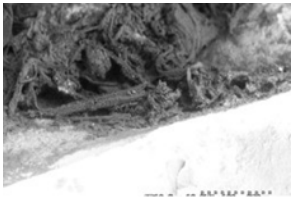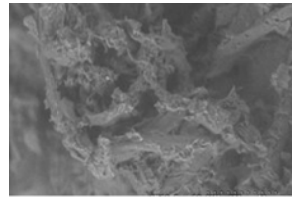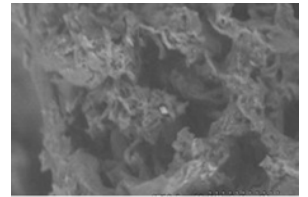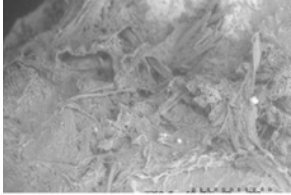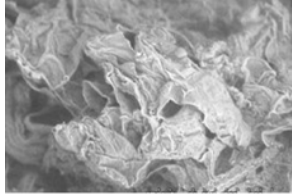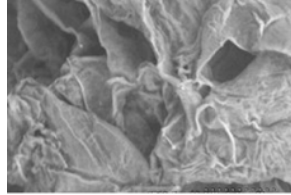
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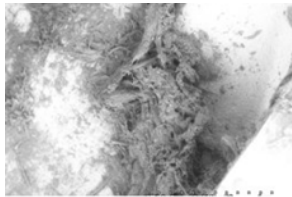
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RS12D_b01.TIF

RS12D_b02.TIF

RS12D_b03.TIF

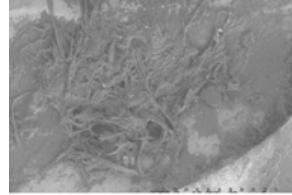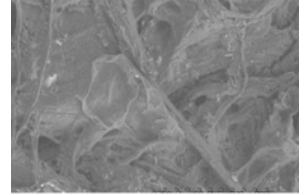RS12D_c01.TIF

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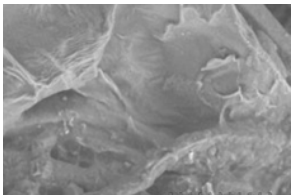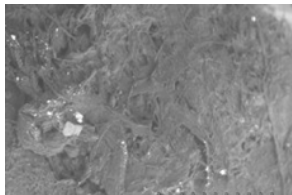
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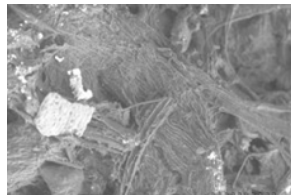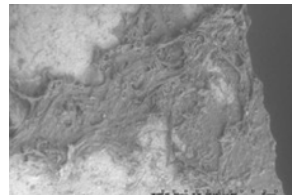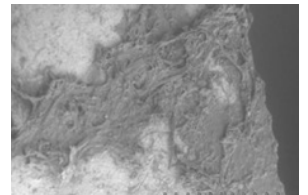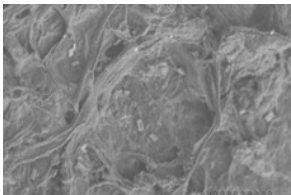

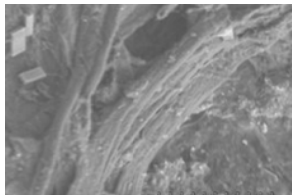RS12D_d02.TIF

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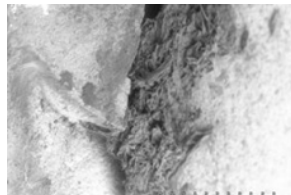RS12D_e01.TIF

RS12D_e02.TIF

RS12D_f01 reduced.tif

RS12D_f01.TIF
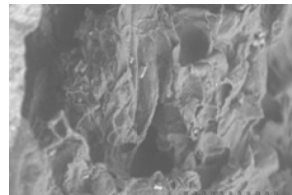

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RS12D_f03.TIF

RS12D_g01.TIF

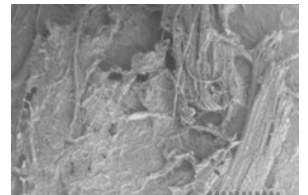RS12D_g02.TIF

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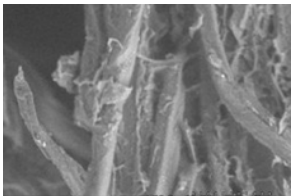
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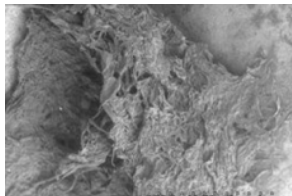
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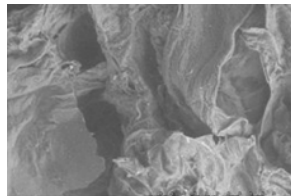
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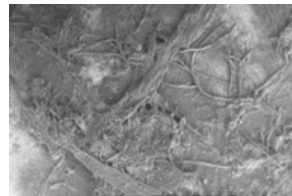
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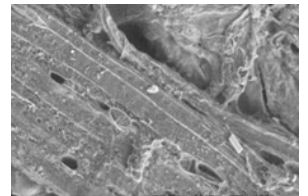
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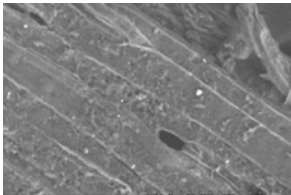
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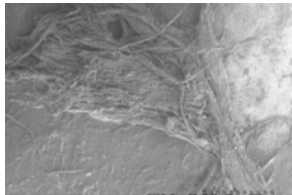
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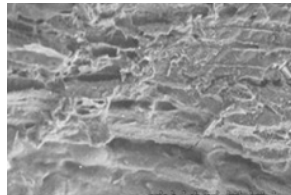
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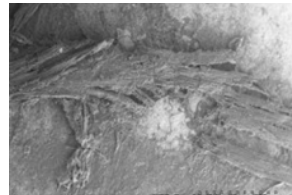
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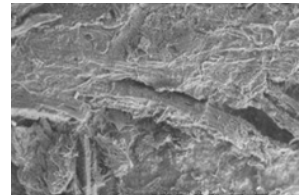
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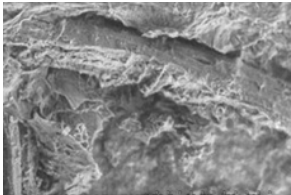
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RS12V_q05.TIF

WD10.2mm 12.0kV x120   250um

WD10.0mm 12.0kV x50   1mm

WD10.0mm 12.0kV x50 1mm

WD10.1mm 12.0kV x600 50um

WD10.1mm 12.0kV x1.2k   25um

WD10.6mm 12.0kV x70   500um

WD10.5mm 12.0kV x500　100um

WD10.5mm 12.0kV x1.2k　25um

WD10.5mm 12.0kV x50   1mm

WD10.5mm 12.0kV x250   200um

WD10.5mm 12.0kV x900   50um

WD10.2mm 12.0kV x50   1mm

WD10.0mm 12.0kV x150 200um

WD10.0mm 12.0kV x50 1mm

WD10.0mm 12.0kV x50   1mm

WD10.0mm 12.0kV x300   100um

WD10.0mm 12.0kV x1.0k 50um

WD10.0mm 12.0kV x50 1mm

WD10.0mm 12.0kV x400   100um

WD10.1mm 12.0kV x60   500um

WD10.0mm 12.0kV x700   50um

WD10.0mm 12.0kV x50   1mm

WD10.1mm 12.0kV x500   100um

WD10.0mm 12.0kV x50   1mm

WD10.0mm 12.0kV x500   100um

WD10.0mm 12.0kV x900   50um

WD10.0mm 12.0kV x60 500um

WD10.1mm 12.0kV x500 100um

WD10.0mm 12.0kV x70   500um

WD10.0mm 12.0kV x250   200um

WD10.0mm 12.0kV x500   100um

WD10.0mm 12.0kV x1.0k   50um